



Nikolaev Institute of Inorganic Chemistry  
Siberian Branch of Russian Academy of Sciences

X-RAY PHOTOELECTRON SPECTROSCOPY AND NEAR  
EDGE X-RAY ABSORPTION FINE STRUCTURE  
SPECTROSCOPY STUDY OF SYNCHROTRON  
RADIATION EFFECTS ON FLUORINATED GRAPHITE  
INTERCALATED NITROGEN TETROXIDE

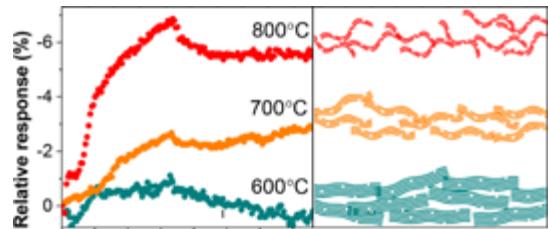
**G.I. Semushkina**, L.G. Bulusheva, G.N. Chekhova, A.V. Okotrub,  
D.V. Pinakov, I.P. Prosvirin, Yu.V. Fedoseeva



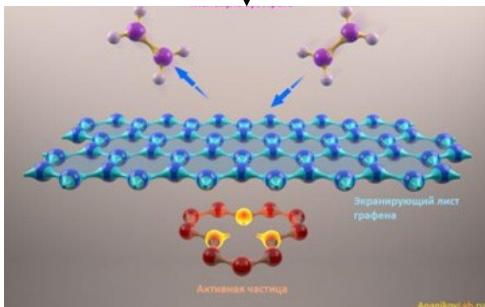
**Synchrotron and Free electron laser Radiation:  
generation and application (SFR-2020)**

# Scientific relevance

Sysoev V.I., Guselnikov A.V., Katkov M.V. and etc.  
// J. Nanophotonics. – 2016, V. 10 – P. 012512.



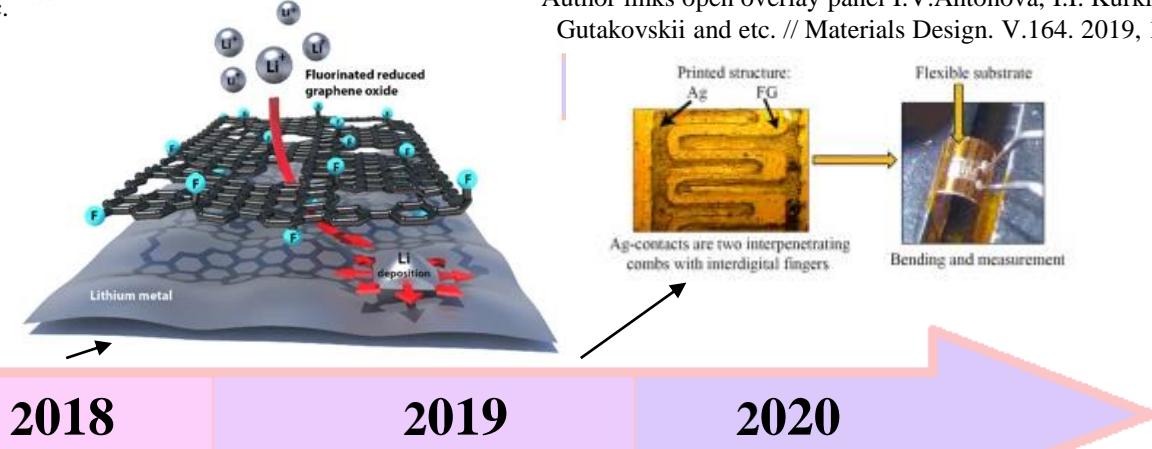
2016



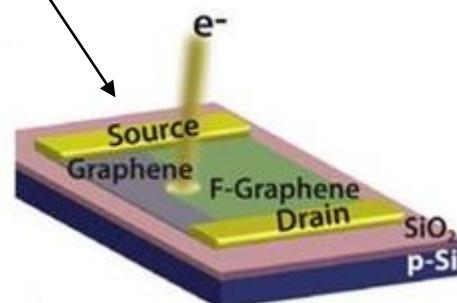
2018

Jerney Bobnar, Matic Lozinsek, Gregor Kapun //  
Scientific Reports. V. 8. 5819. 2018.

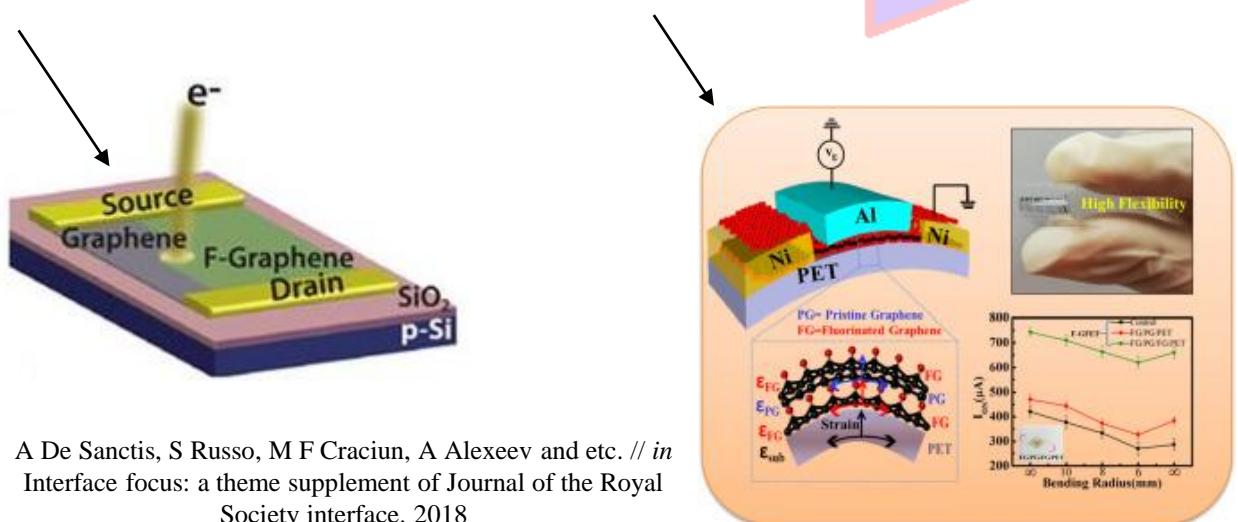
Author links open overlay panel I.V.Antonova, I.I. Kurkina, A.K. Gutakovskii and etc. // Materials Design. V.164. 2019, 107526



2019



2020

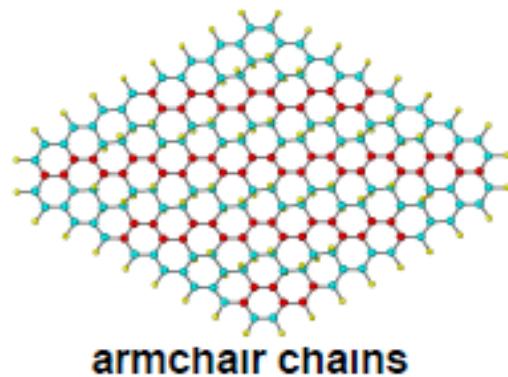


A. E. Sedykh, E. G. Gordeev, E. O. Pentsak and V. P. Ananikov // Phys. Chem. Chem. Phys. 2016, 18, 4608.

A De Sanctis, S Russo, M F Craciun, A Alexeev and etc. // in Interface focus: a theme supplement of Journal of the Royal Society interface. 2018

Mamina Sahoo, Jer-Chyi Wang, Yuta Nishin // Applied Surface Science. 2020.V.499, 143839

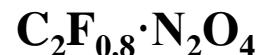
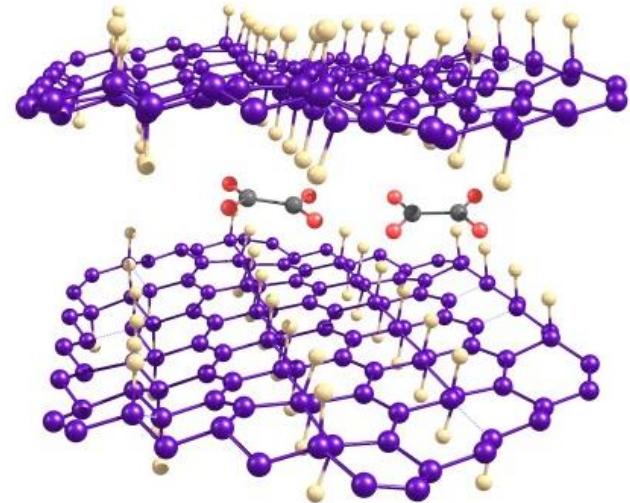
# The object of study



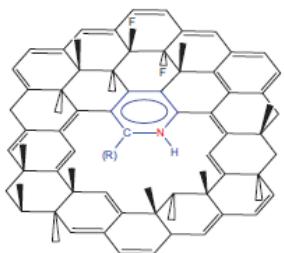
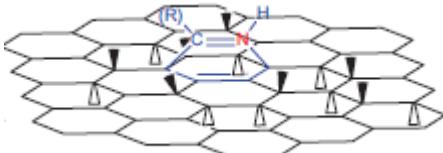
L.G. Bulusheva, A.V.Okorub, N.F. Yudanov Physi.  
Low-Dim. Struct. 7/8 (2002) pp.1-14  
A.Vyalikh, L. Bulusheva, Igor G. Chekhova and etc. //  
J. Phys. Chem. C 2013, 117, 7940-7948

A. V. Okotrub, N. F. Yudanov, I. P. Asanov and etc. //  
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T.L. Makarova, V.S. Zagaynova, G. Inan, A.V. Okotrub,  
G.N. Chekhova, D.V. Pinakov, L.G. Bulusheva //  
J. Supercond Nov Magn. 2012. V. 25, № 1, p. 79-83.



3) Substitution of  $Br_2$  with  $CH_3CN$  until the liquid phase becomes discolored.



Yu. V. Fedoseeva,A.V.Okorub, I. P.Asanov and etc.// Phys. Status Solidi B 251. 2014. No. 12, -P. 2530–2535



The **main goal** is to determine the mechanism of interaction of  $\text{N}_2\text{O}_4$  with a matrix of semifluorinated graphite and related intermediate reaction products under the influence of external factors.

The **objective**: to carry out a detailed investigation of the electronic structure of intercalated by  $\text{N}_2\text{O}_4$  semifluorinated graphite  $\text{C}_2\text{F}_{0.8}$  before and after thermal exposure and irradiation with zero-order light from synchrotron (the so-called "white light").

# Experimental

**FTIR spectra** - Scimitar FTS 2000 spectrometer.

Thermal exposure - for **10** minutes at a temperature of **190-200 °C**

The **XPS** and **NEXAFS** experiments for  $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$  - monochromatized synchrotron radiation from the Russian–German beamline (RGBL) at BESSY II, Germany.

Additional XPS studies were conducted at the Boreskov Institute of Catalysis on an ESCA-Specs spectrometer.



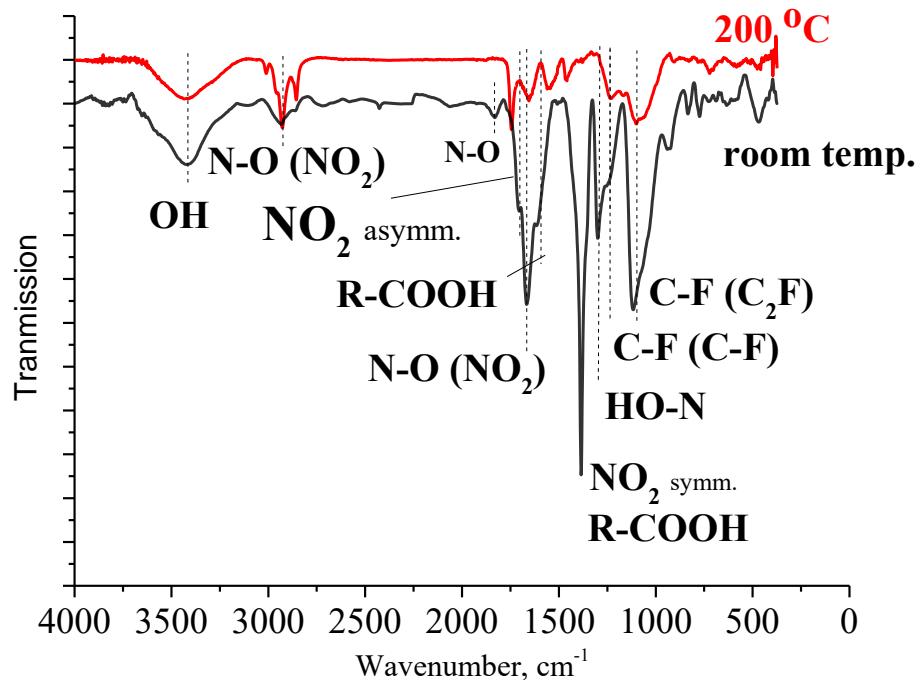
**Influence with zero-order light illumination from the RGBL of BESSY II on the sample  $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ .**

- Energy range 30-1300 eV.
- Total energy flow over all wavelengths  $\Phi \approx 2 \times 10^{-3}$  J/s.
- Under illumination for 180 s. total energy  $E_{\text{tot}} \approx 0.36$  J.
- Dose =  $9 \times 10^5$  J/kg.

## **The scheme of our experiment included:**

1. Measurement of XPS and NEXAFS spectra of a sample.
2. Illumination of a sample by zero-order light for 180 seconds
3. Repeated measurement of the XPS and NEXAFS spectra.

# Investigation of the effect of thermal exposure on $\text{C}_2\text{F}_{0.8} \cdot \text{N}_2\text{O}_4$ using IR spectroscopy



Possible chemical reactions,  
flowing on the surface  $\text{C}_2\text{F}_{0.8}$ :

- $\text{NO}_2 + \text{NO}_2 \rightarrow \text{NO} + \text{NO}_3$
- $2(\text{NO}_2 + \text{NO}) \rightarrow 2\text{NO}_3 + \text{N}_2$
- $3\text{NO}_2 + \text{H}_2\text{O} \rightarrow 2\text{HNO}_3 + \text{NO}$

Structural fragments	wavenumber, $\text{cm}^{-1}$	Ref.
$\text{C-F (C}_2\text{F)}$	1099	[1]
$\text{C-F (CF)}$	1234	[1]
$\text{HON (HNO}_3)$	1300	[2]
$\text{NO}_2 (\text{HNO}_3)$	1340 sym. 1709 asym.	[2]
$\text{R-COOH}$	1385 1600	[3]
$\text{C=C}$	1570	[4]
$\text{N-O (NO}_2)$	1660 2936	[5]
$\text{OH}$	3424	[2]

[1] Frantisek Karlick, Kasibhatta Kumara Ramanatha Datta, Michal Otyepka, and Radek Zboril. // ACS Nano. VOL. 7 ' NO. 8 -2013. -P. 6434–6464.

[2] NIST Inorganic Crystal Structure Database (ICSD) <https://webbook.nist.gov>

[3] Weikang Zhu, Xiangwen Zhang and etc. In-situ electrochemical activation of carbon fiber paper for the highly efficient electroreduction of concentrated nitric acid // Electrochimica Acta, 2018, 291. –P.328-334.

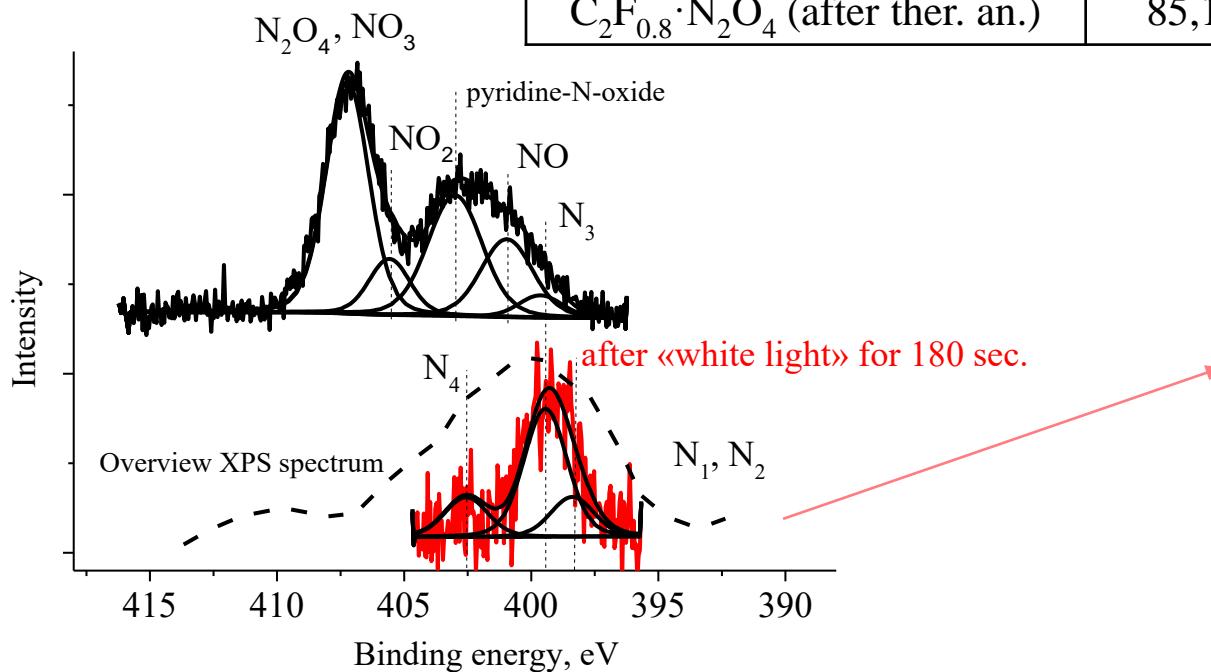
[4] M. Praveen Kumar, T. Kesavan, Golap Kalita, P. Ragupathy and etc . // RSC Adv. 2014, 4, 38689

[5] <https://www.gasmet.com/products/tools/spectrum-library/nitrogen-dioxide/>

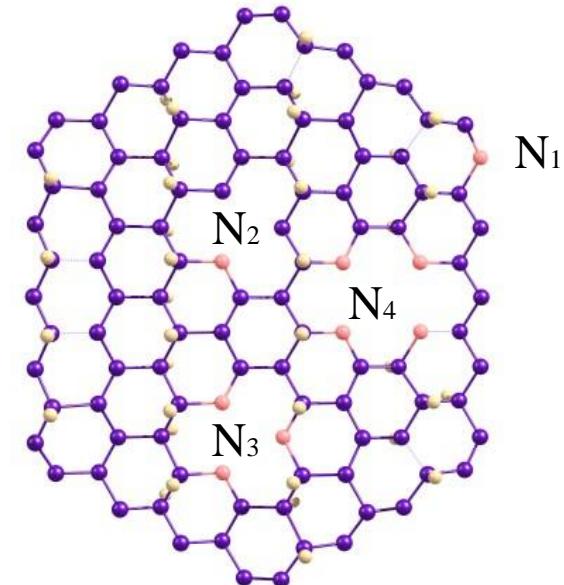
# Investigation of the effect of thermal annealing and «white light» illumination on $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ using XPS

Elemental composition of the sample surface  $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$  before and after white light illumination for 180 sec.

XPS N(1s)

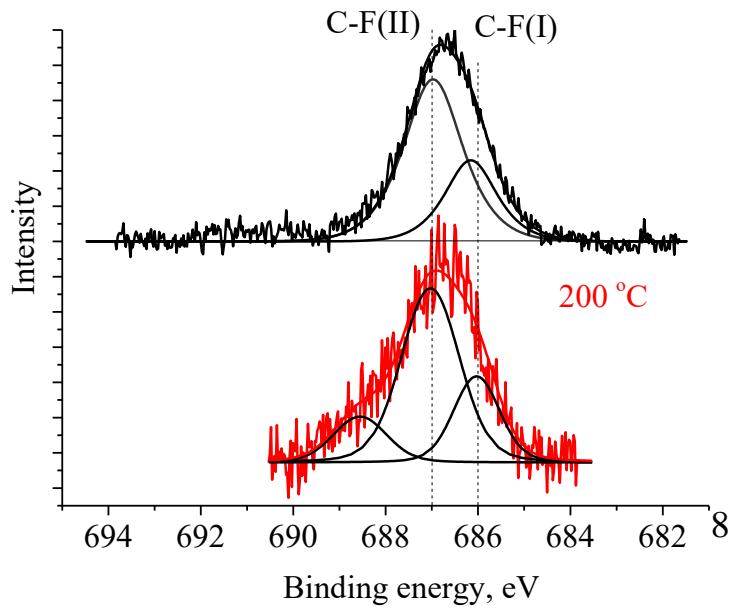
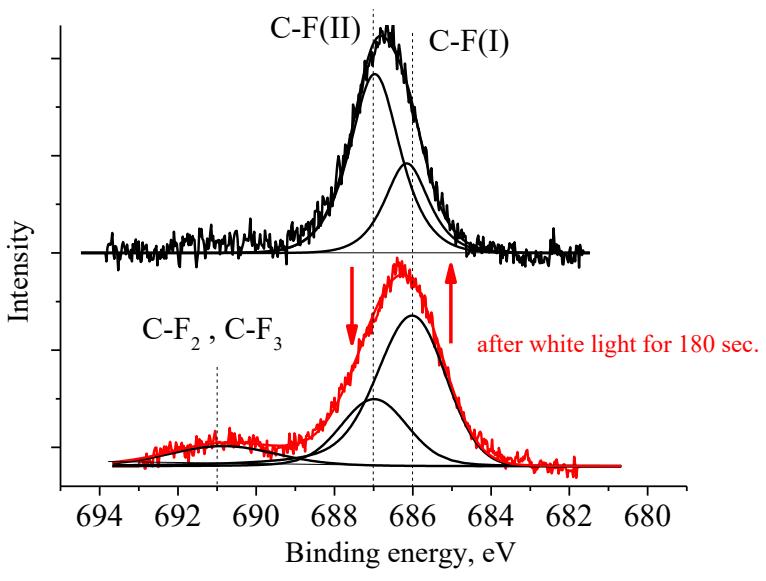
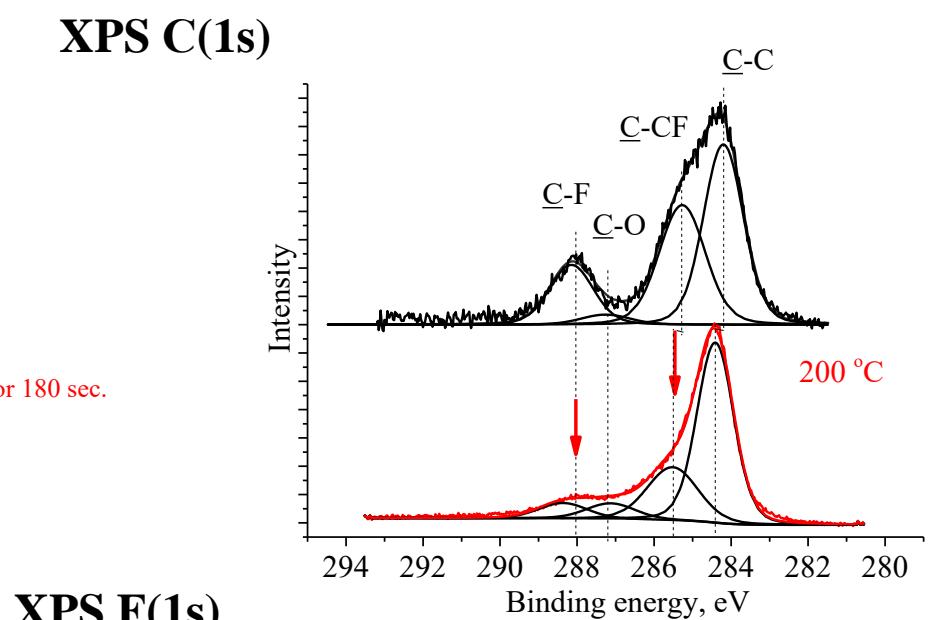
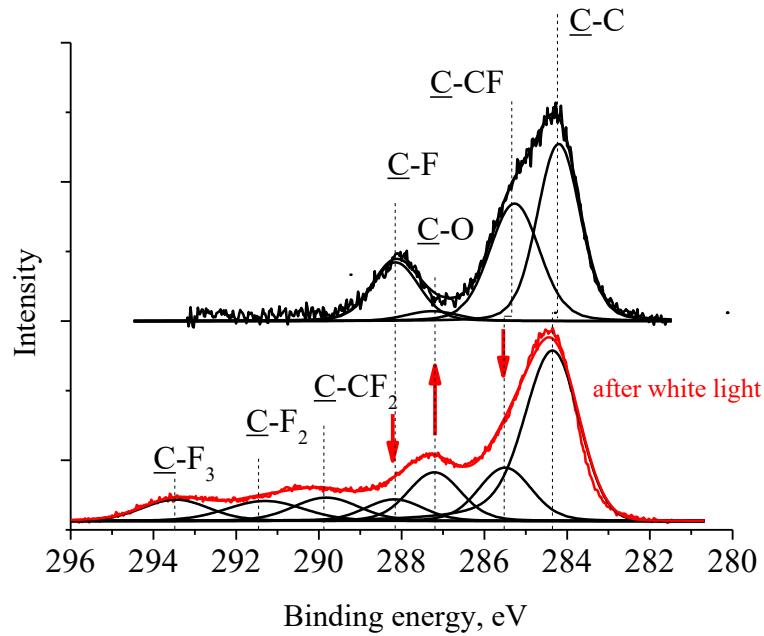


Образец	C, %	F, %	N, %	O, %
$\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ (before wh.light)	67,6	23,5	3,7	5,2
$\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ (after wh.light)	85,4	8,5	2,1	4,0
$\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ (after ther. an.)	85,1	5,7	-	9,2

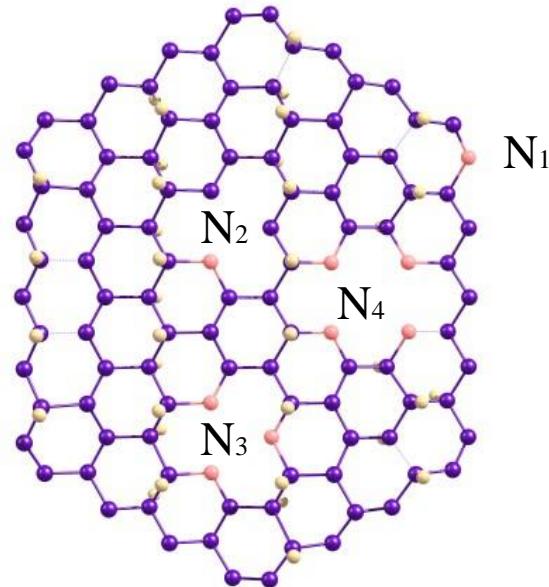
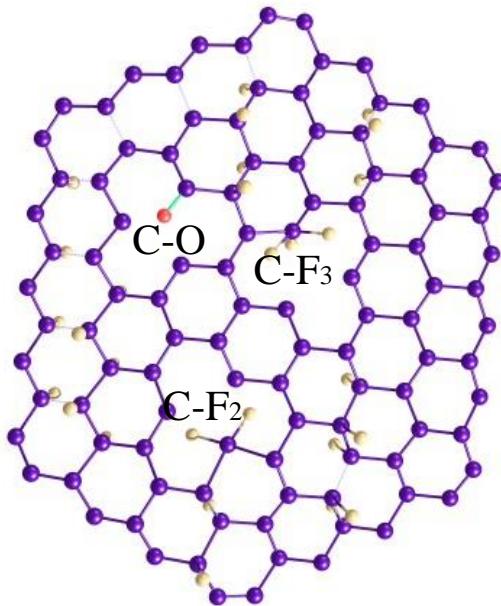


Thermal exposure **200 °C** for 10 minutes leads to the removal of nitrogen-containing functional groups from the surface  $\text{C}_2\text{F}_{0.8-0.9}\cdot\text{N}_2\text{O}_4$

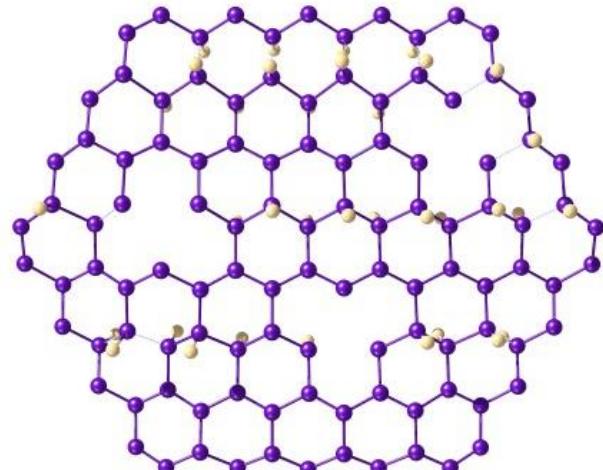
# Investigation of the effect of thermal annealing and «white light» illumination on $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ using XPS



The effect of «white light» exposure on surface  $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$  for 180 sec.

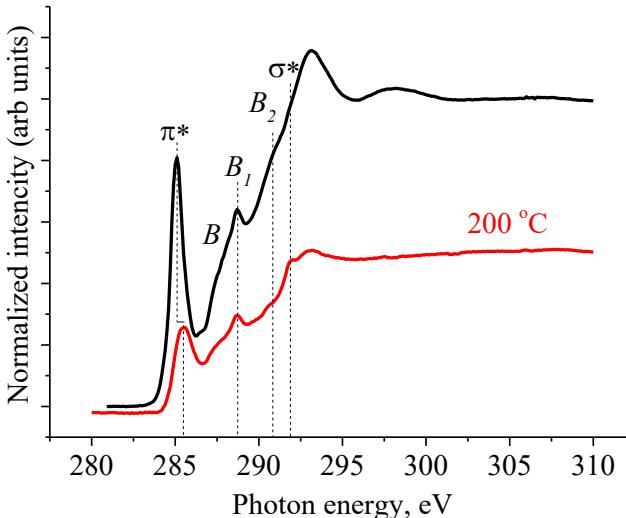
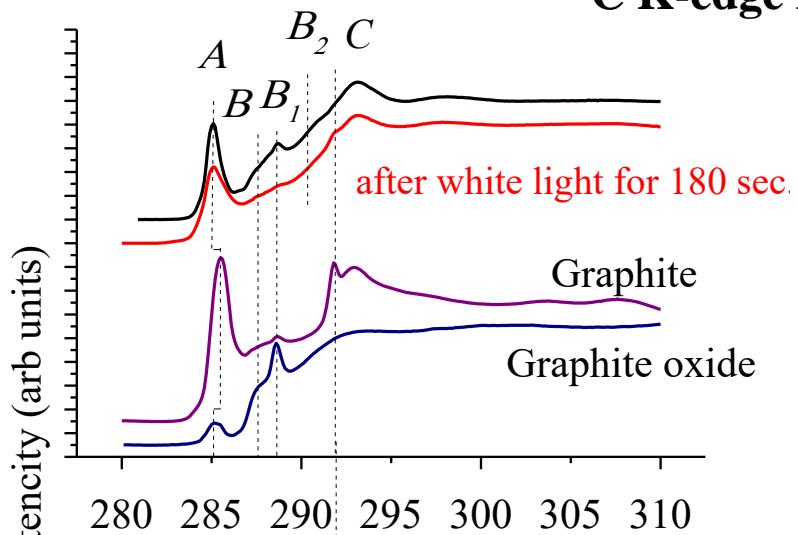


The effect of thermal exposure (200 °C) on  
surface  $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$  for 10 minutes

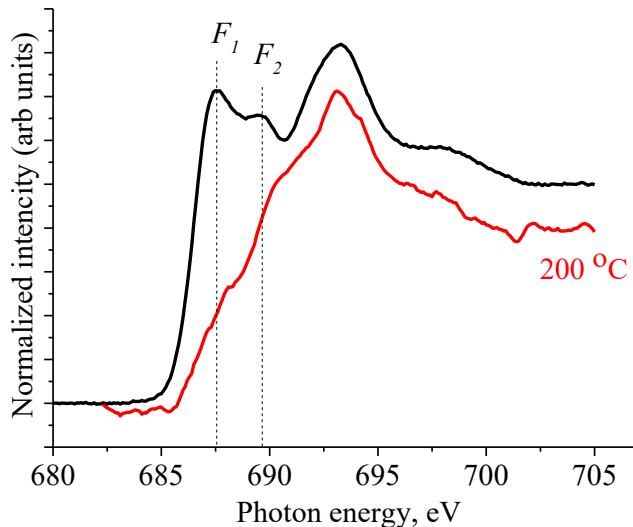
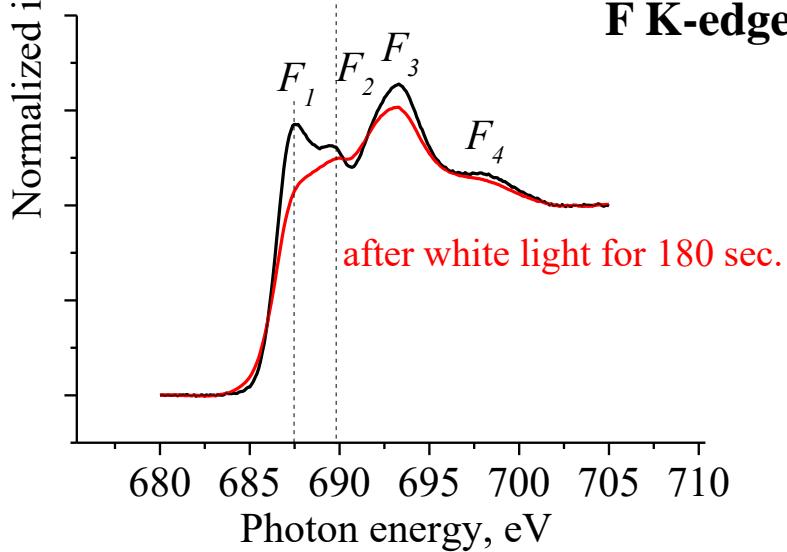


# Investigation of the effect of thermal and «white light» exposure on $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$ by NEXAFS

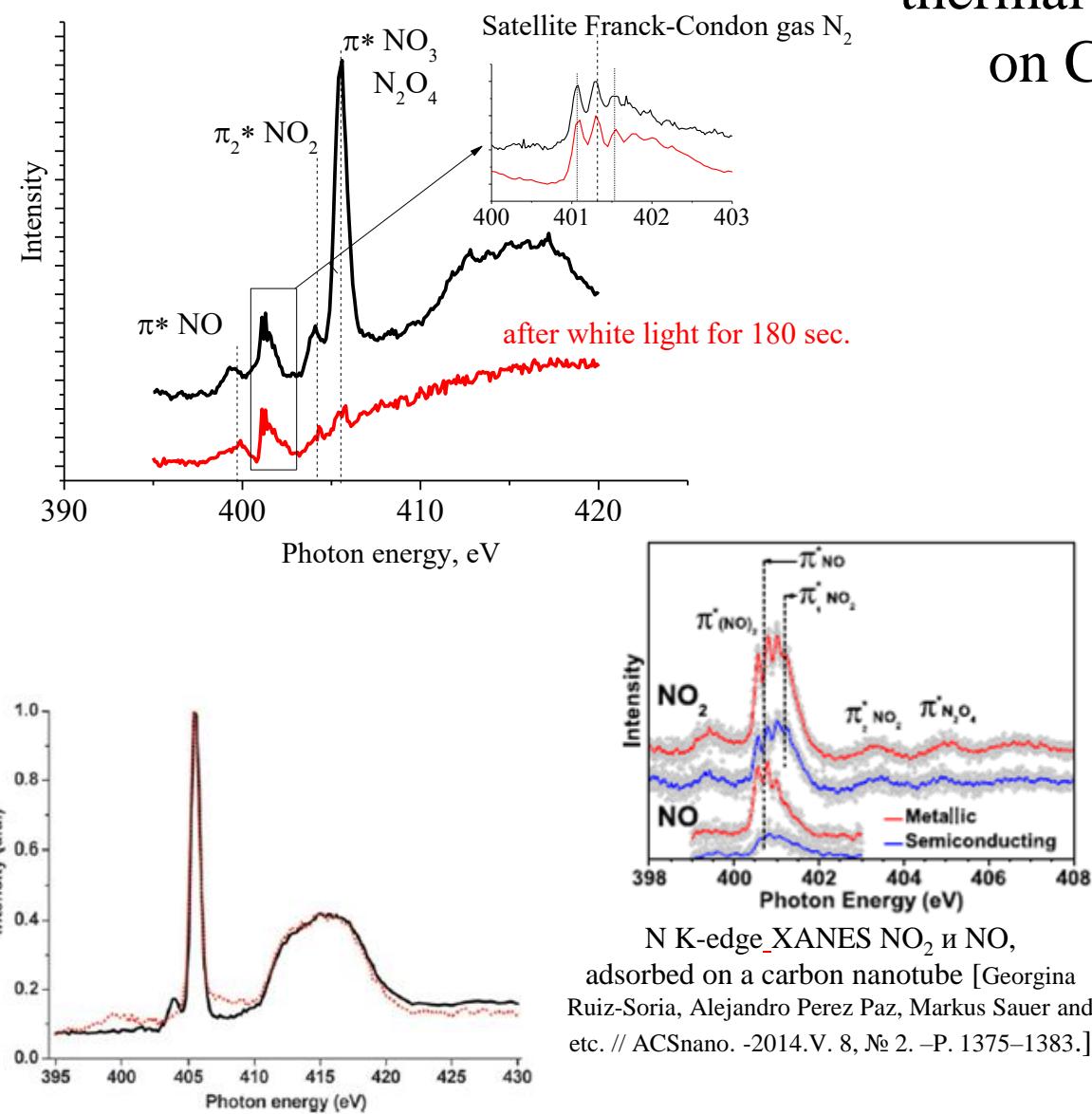
## C K-edge NEXAFS



## F K-edge NEXAFS



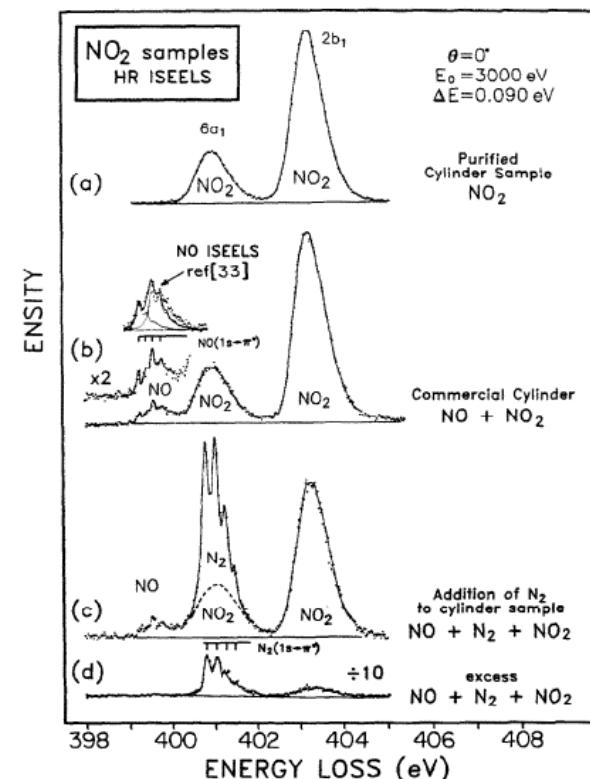
## N K-edge NEXAFS



N K-edge XANES NO<sub>2</sub> и NO,  
adsorbed on a carbon nanotube [Georgina  
Ruiz-Soria, Alejandro Perez Paz, Markus Sauer and  
etc. // ACS nano. -2014.V. 8, № 2. -P. 1375–1383.]

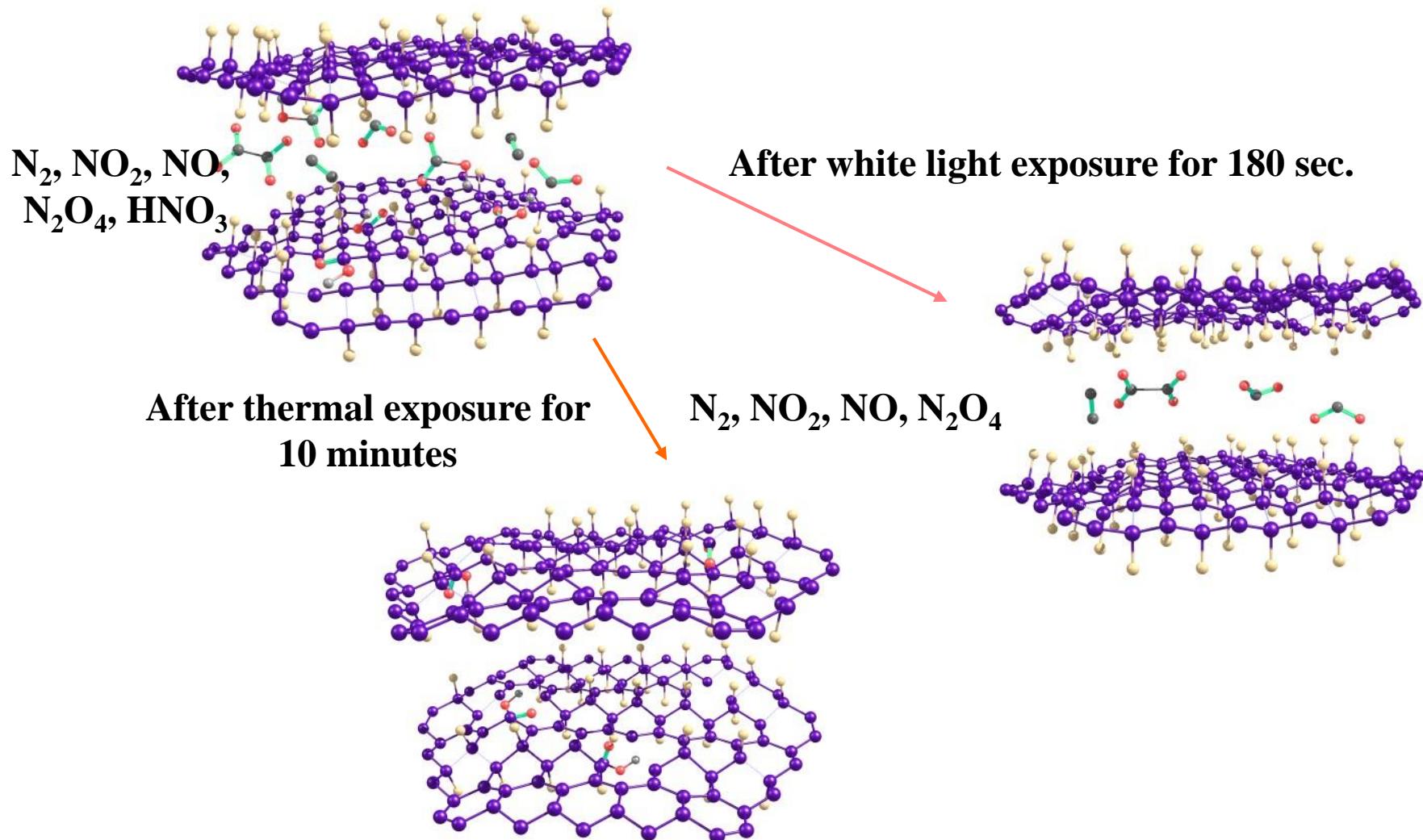
N K-edge NEXAFS of ice with HNO<sub>3</sub> [A. Krepelova, J. Newberg, T. Huthwelker  
and etc. // Phys. Chem. Chem. Phys., 2010, 12, 8870–8880].

## Investigation of the effect of thermal and «white light» exposure on C<sub>2</sub>F<sub>0.8</sub>·N<sub>2</sub>O<sub>4</sub> by NEXAFS



Investigation of sample purity in NO<sub>2</sub> cylinders by high-resolution ISEELS measurements in the N 1s region: (a) purified NO<sub>2</sub>; (b) cylinder NO<sub>2</sub> (unpurified) showing NO impurity and the high-resolution NO spectrum; (c) Addition of N<sub>2</sub> to cylinder NO<sub>2</sub>; (d) Same as (c) but with excess N<sub>2</sub> [W. ZHANG, K.H. SZE, C.E. BRION // Chemical Physics 140 (1990) 265–279].

# The effect of thermal and «white light» exposure on bulk $\text{C}_2\text{F}_{0.8}\cdot\text{N}_2\text{O}_4$



# Conclusions

1. The fluorinated graphite matrix can be used as a nanoreactor. Substitution of intercalate - acetonitrile with nitrogen tetroxide, which is in equilibrium with nitrogen dioxide, leads to the formation of nitrogen-containing molecules  $\text{HNO}_3$ ,  $\text{NO}$ ,  $\text{N}_2$  in the interlayer space  $\text{C}_2\text{F}_{0.8}$ .
2. The effect of the zero-order beam from RGBL BESSY II exposure on the  $\text{C}_2\text{F}_{0.8} \cdot \text{N}_2\text{O}_4$  sample for 180 seconds leads to partial defluorination of the sample with the possible removal of carbon and the formation of vacancy defects. At the edge of the fluorine graphite plane, the formation of the  $\text{C}-\text{F}_2$ ,  $\text{C}-\text{F}_3$ ,  $\text{C}-\text{O}$  bond occurs and included pyridine groups are observed.
3. It was found that by thermal shock  $\text{HNO}_3$  is removed from the semifluorinated graphite matrix with the preservation of the remaining nitrogen-containing intercalate groups:  $\text{NO}$ ,  $\text{NO}_2$ ,  $\text{N}_2$ ,  $\text{N}_2\text{O}_4$ .
4. Annealing at  $\sim 200$  °C of sample  $\text{C}_2\text{F}_{0.8} \cdot \text{N}_2\text{O}_4$  for 10 minutes facilitates the production of an “empty” matrix with partial defluorination and the formation of vacancy defects.

This work was supported by RFBR grant № 18-29-19073 MK.

**THANKS FOR ATTENTION !!!**